

AI MOLECULAR
HAIR SCIENCE

AI MOLECULAR HAIR SCIENCE

MASK DAMAGE REPAIR

A nourishing and protective mask that helps maintain healthy hair, leaving it soft and shiny. Its lightweight formula detangles and softens hair, while K4Power® Polypeptide helps revitalize it during washing. Protects against damage for up to 3 days from UV rays, mechanical styling, and environmental aggressors.

A Nourishing And Protective
Hair Mask With Polypeptide



HOW TO USE



SCAN ME

Minimal Ingredients
Maximum
Efficacy

01

TECHNOLOGY

Clinically proven, this mask protects hair from damage caused by UV rays, styling tools, and environmental aggressors for up to 3 days after application. It strengthens, softens, and detangles hair.

- **Protects against damage:** Revitalizing protection against damage caused by UV rays, environmental aggressors, and daily mechanical styling for up to 3 days.
- **Preserves hair health:** Strengthens the hair's outer lipid barrier to make it more resilient and stronger. K4Power® Polypeptide compensates for protein loss during washing.
- **Enhances hair's natural shine:** Its pH-optimized formula minimizes excessive cuticle swelling during washing to help keep hair smooth and maximize its shine.
- **Softens, smooths, and detangles:** Free from silicone and film-forming waxes that can build up over time and weigh hair down. **Ideal for all hair types, including colored hair.**

02

DIRECTIONS FOR USE

Apply to damp hair after using AI Molecular Hair Science Shampoo Damage Repair, leave on for 5 minutes, massage well, then rinse.

03

INGREDIENTS

Aqua, Propylene Glycol, Cetearyl Alcohol, Behentrimonium Chloride, Polysorbate 20, polypeptide Amino Acids (K4Power®), PEG-7 Glyceryl Cocoate, Olea Europaea (Fruit Oil), Argania Spinosa (kernel oil), Hydrolyzed Wheat Protein, Hydrolyzed keratin, Isopropyl Alcohol, Tocopheryl Acetate, Phenoxyethanol, Potassium Sorbate, Citric Acid, Fragrance (Parfum), Benzyl Alcohol.